

REMARKS

Two paragraphs of the specification and claim 20 are herein amended to correct additional typographical errors found (replacing "ground plan" with "ground plane").

Thus, claims 1-26 remain pending in the application.


Further, Applicants have discovered an error in Fig. 2 of the formal drawings. The informal drawing of Fig. 2 shows the correct connections of elements 220, 212 and 210, while the previously submitted formal drawing of Fig. 2 showed incorrect connections of element 220, 212 and 210. Accordingly, Applicants herewith submit a new set of replacement formal drawings, where Fig. 2 now shows the correct connections as originally shown in the informal drawings.

SUMMARY

In light of the above remarks, reconsideration is respectfully requested. It is further submitted that the application is now in condition for allowance and early notice of the same is earnestly solicited.

Respectfully submitted,

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